## **Refine Search**

## Search Results -

Terms	Documents
L4 and (width\$1 near4 (feature\$1 or pattern\$1))	34

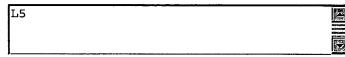
US Pre-Grant Publication Full-Text Database

US Patents Full-Text Database US OCR Full-Text Database

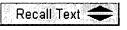
Database:

EPO Abstracts Database
JPO Abstracts Database
Derwent World Patents Index
IBM Technical Disclosure Bulletins

Search:











## **Search History**

DATE: Wednesday, October 27, 2004 Printable Copy Create Case

Set Name side by side	Query	<u>Hit</u> <u>Count</u>	Set Name result set
DB=P	PGPB, USPT, USOC, EPAB, JPAB, DWPI, TDBD; PLUR=YES; OP=ADJ		
<u>L5</u>	L4 and (width\$1 near4 (feature\$1 or pattern\$1))	34	<u>L5</u>
<u>L4</u>	(second adj2 (exposure or irradiat\$5)) same (resist or photoresist) same mask same opening\$1	133	<u>L4</u>
DB=F	PGPB; PLUR=YES; OP=ADJ		
<u>L3</u>	(second adj2 (exposure or irradiat\$5)) same (resist or photoresist) same mask	202	<u>L3</u>
DB=P	PGPB, USPT, USOC, EPAB, JPAB, DWPI, TDBD; PLUR=YES; OP=ADJ		
<u>L2</u>	(second adj2 (exposure or irradiat\$5)) same (resist or photoresist) same (mask adj1 opening\$1)	7	<u>L2</u>
<u>L1</u>	(second adj2 (exposure or irradiat\$5)) same (resist or photoresist) same (mask or pattern or opening\$1)	1448	<u>L1</u>

## **END OF SEARCH HISTORY**